# Cascade Summit 11000 200 mm Manual Probe System

# 000111110001

## **>** Overview

Summit™ series manual probe system, with PureLine™ and AttoGuard® technology, allow you to access the full range of your test instruments for 200 mm and 150 mm wafers. Whatever your application: RF/Microwave, device characterization, wafer level reliability, e-test, modeling, or yield enhancement, Summit series platforms lead the industry in on-wafer measurements. Summit series probe stations are easy to configure with your choice of measurement performance, manual or semi-automated operation, chuck size, thermal range and microscope options. All platforms are -60°C to 300°C compatible to ensure an upgrade path to meet your future needs.

The powerful Velox™ for manual probe stations control software features easy on-screen navigation and seamless integration with analyzers and measurement software. It enables simple operation of motorized positioners and thermal systems. For a wide range of applications, the Summit probe station powered by Velox software achieves high test efficiency.



## > Features / Benefits

Measurement accuracy	<ul> <li>Best solution for low-noise and 1/f measurements with advanced PureLine, AttoGuard and MicroChamber® technologies</li> <li>Minimize AC and spectral noise with effective shielding capability</li> </ul>	
Positioning accuracy	• Manual 3-axis stage enables fast, accurate "hands on" wafer positioning with ergonomic controls	
Productivity	• eVue™ digital imaging system: enhanced optical visualization, fast set-up	
Flexibility and application- tailored solutions	<ul> <li>RF/microwave device characterization, 1/f, WLR, FA and design debug</li> <li>Complete solution for small- and large-area multi-site probe cards</li> <li>Seamless integration between Velox and analyzers/measurement software</li> </ul>	
Ease of use	<ul> <li>Quick, safe, and comfortable wafer access via locking roll-out stage</li> <li>"Hands-free" microscope remote control</li> <li>Intuitive ergonomic controls, enable fast setup and test data gathering</li> <li>Easy navigation and operation of motorized positioners and thermal systems with Velox</li> </ul>	



## > Mechanical Performance

## X-Y Travel

Travel	203 mm x 203 mm (8 in. x 8 in.)	
Motion control	Manual controls (X-Y direct rotary knobs)	
Resolution	5 mm / turn	

## **Z** Stage

Travel	Fixed Z mount

## Theta Stage

Travel	± 5.7°
Resolution	0.8° / turn

<sup>\*</sup> Measured at edge of 200 mm chuck

## System

•			
Probe-force capability	20 kg (44 lb.) maximum		
Probe-force deflection	$\leq$ 0.0015 $\mu$ m/ $\mu$ m slope per 10 kg load		
System planarity	≤ 35 µm (1.3 mils) @ 25°C		
	≤ 35 μm (1.3 mils) @ -60°C (typical)		
	≤ 35 μm (1.3 mils) @ 200°C (typical)		
	≤ 50 μm (2.0 mils) @ 300°C (typical)		

2



## **>** MicroChamber

Electrical	Summit 11000B-AP		
EMI shielding	≥ 20 dB 0.5-3 GHz, ≥ 30 dB 3-20 GHz (typical)		
Spectral noise floor*	≤ -170 dBVrms/rtHz (≤1 MHz) Non thermal		
	≤ -170 dBVrms/rtHz (≤ 1 MHz) Thermal ATT		
System AC noise **	≤ 5 mVp-p (≤ 1 GHz) Non thermal		
	≤ 5 mVp-p (≤ 1 GHz) Thermal ATT		

<sup>\*</sup> Typical results. Actual values depends on probe / test setup. Test setup uses triaxial thermal chuck, 50  $\Omega$  termination, high quality LNA, and DSA/DSO instrument.

## **Light Shielding**

Туре	Complete dark enclosure around chuck		
Wafer access	Front access door with rollout stage for easy wafer loading		
Probe compatibility	Standard MicroChamber TopHat™ allows access for up to eight probes		
Light attenuation	≥ 120 dB		

## **Purge and Condensation Control**

Test environment	Low volume for fast purge, external positioning and cable access to maintain sealed environment	
Dew point capability	> -70°C for frost-free measurements and high-voltage measurements*	
Purge gas	Dry air or nitrogen	
Purge flow rate	Standard purge - manual controls, variable 0 to 110 l/min (4 CFM) at SATP**	
	Quick purge - manual controls, standard purge rate or maximum > 110 l/min (4 CFM) at SATP**	
Purge time	< 15 min for measurements @ -55°C (typical)	
External condensation control	Integrated laminar-flow air distribution on external MicroChamber surfaces to eliminate condensation	
	Controls for ON/OFF and flow rate for both top and bottom surfaces	

<sup>\*</sup> Please see the facilities guide for air requirements to enable optimum dew point for low-temperature measurements using a thermal chuck inside the MicroChamber.

## > Platen System

## Platen

Lift control

Platen			
Material	Steel for magnetic positioners		
Dimensions	74.5 cm (W) x 59.5 cm (D) x 20 mm (T) (29.3 in. x 23.4 in. x 0.78 in.)		
Mounting system	Kinematic 4 point		
Platen to chuck height	14 ± 0.5 mm (0.55 ± 0.02 in. )		
Accessory compatibility	Minimum of 8 DC or 4 RF positioners allowed, compatible simultaneous probe card holder use		
Thermal management	Integrated laminar-flow air-cooling for thermal expansion control		
Platen Ring Insert			
Material	Steel for magnetic positioners		
Weight	4.5 kg (9.9 lb.)		
Standard interface	For MicroChamber, TopHat, probe card holders and custom adapters		
Platen Lift			
Туре	Precision 4-point linear lift		
Range	5.0 mm (0.20 in.)		
Repeatability	≤ 3 µm (0.12 mils)		

Ergonomic handle with 90° stroke. Optional micrometer control for fine adjustment of probe card contact.



<sup>\*\*</sup> Test setup: Station power ON, Thermal system ON (40°C), MicroChamber closed, guard to shield shorted with triax adapter on chuck. Instrument setup: Time domain digital scope (DC to 1 GHz), 50 Ω input impedance, cable to chuck BNC connector. Measurement: Peak-Peak Noise Voltage (acquire 1000 data points, and calculate mean of Vp-p data).

## > Wafer and Aux Chuck Design

#### Wafer Chuck

	FemtoGuard	MicroVac™	Hi-ISO	Basic
Туре	Triax			
Material *	Ni or Au			
Vacuum interface	Standard (35 holes)	MicroVac ** (495 Micro-holes, best for thin wafers)	Standard (35 holes)	Rings
Diameter				
Thermal 200 mm (8 in.)	•	•	•	•
Non-Thermal 200 mm (8 in.)	•	•	•	
Non-Thermal 150mm (6 in.)			•	
AUX chucks (integrated)	2	2	2	Optional
DUT sizes supported	Shards or wafers 50 mm (2 in.) through 200 mm (8 in.) Optional single-die accessory available.			
Vacuum zones	4	5	4	3
Vacuum diameters ***	10, 70, 141, 180 mm (0.4, 2.8, 5.5, 7 in.)	10, 70, 93, 144, 178 mm (0.4, 2.8, 3.6, 5.6, 7 in.)	10, 70, 141, 180 mm (0.4, 2.8, 5.5, 7 in.)	16, 130, 190 mm (0.6, 5, 7 in.)
Vacuum actuation	Easy access multi-zone manual vacuum controls, and software control (semi-automated)			

<sup>\*</sup> Nickel (Ni) plated aluminum or Gold (Au) plated aluminum

## **Auxiliary Chuck**

Quantity	Two, integrated with wafer chuck assembly	
Substrate size (maximum)	15.2 mm x 22.1 mm (0.59 in. $\times$ 0.87 in.) ISS substrate 19 mm $\times$ 19 mm (0.75 in. $\times$ 0.75 in.) substrate	
Material	Steel (Magnetically loaded, RF absorbing Eccosorb available)	
Thermal isolation	Ensures negligible load drift on ISS	
Flatness	≤ 8 µm (0.3 mils)	
Vacuum actuation	Independently controlled apart from wafer vacuum zones	

4

## > Velox™ Probe Station Control Software

The Summit is optionally equipped with Velox probe station control software. Operating system is Windows 10.



<sup>\*\*</sup> Patented MicroVac technology using 495 micro-hole pattern for uniform vacuum hold down of thin, warped and partial wafers, and uniform temperature conductivity.

<sup>\*\*\*</sup> Diameter of arranged vacuum hole patterns (or vacuum rings) into individual zones

## Non-Thermal Modular Chucks

## FemtoGuard® Chuck Performance (150/200 mm)

Breakdown voltage	Force-to-guard	≥ 500 V	
	Guard-to-shield	≥ 500 V	
	Force-to-shield	≥ 500 V	
Resistance	Force-to-guard	$\geq$ 1 x 10 <sup>12</sup> $\Omega$	
	Guard-to-shield	$\geq 1 \times 10^{12} \Omega$	
	Force-to-shield	$\geq 5 \times 10^{12} \Omega$	

#### MicroVac / Hi-ISO Coaxial Chuck Performance (150/200 mm)

Breakdown voltage	≥ 500 V
Resistance	$\geq 1 \times 10^{12} \Omega$

#### **System Electrical Performance**

Station with chuck			
(non-thermal)	FemtoGuard	MicroVac / Hi-ISO	
Probe leakage *	≤ 1 fA	≤ 1 fA	
Chuck leakage *	≤1 fA	≤ 600 fA	
Residual capacitance	≤1.0 pF	N/A	
Capacitance variation **	≤ 3 fF	≤ 75 fF	
Settling time	≤ 50 fA @ 50 ms (typical)	N/A	

NOTE: Results measured with non-thermal chuck at standard probing height (5,000 µm) with chuck in a dry environment. Moisture in the chuck may degrade performance.

5



<sup>\*</sup> Overall leakage current is comprised of two distinctly separate components: 1) offset, and 2) noise. Offset is the DC value of current due to instrument voltage offset driving through isolation resistance. Noise is low frequency ripple superimposed on top of offset and is due to disturbances in the probe station environment.

Noise and leakage are measured with a 4156C NOISE.dat CMI program or equivalent; 4 ms sample rate, auto scale, 1 nA compliance, 1 NPLC integration

Settling time is measured with a 4156C SETLB.dat CMI program or equivalent; 2 ms sampling rate, limited auto 1 nA, 1 µA compliance, 3 NPLC integration.

<sup>\*\*</sup> This is chuck capacitance variation based upon chuck position anywhere in the 200 mm area, as measured by a stationary dc probe. Test conditions: Agilent 4284A LCR meter (Cp-d,1 Mhz,4 Average,0 Power), DCP-150, 75 µm above chuck surface, 4-wire connection (HiZ/Hipot to chuck, Loz/Lopot to Probe).

## > Thermal Modular Chucks

## FemtoGuard Chuck Performance (200 mm)

		Thermal Chuck @ -60/-55°C	Thermal Chuck @ 25°C	Thermal Chuck @ 200°C	Thermal Chuck @ 300°C
Breakdown voltage	Force-to-guard	≥ 500 V	≥ 500 V	≥ 500 V	≥ 500 V
	Guard-to-shield	≥ 500 V	≥ 500 V	≥ 500 V	≥ 500 V
	Force-to-shield	≥ 500 V	≥ 500 V	≥ 500 V	≥ 500 V
Resistance	Force-to-guard	$\geq 1 \times 10^{12} \Omega$	$\geq 1 \times 10^{12} \Omega$	$\geq$ 5 x 10 <sup>11</sup> $\Omega$	$\geq 1 \times 10^{11} \Omega$
	Guard-to-shield	$\geq 1 \times 10^{12} \Omega$	$\geq$ 1 x 10 <sup>12</sup> $\Omega$	$\geq 5 \times 10^{11} \Omega$	$\geq 1 \times 10^{11} \Omega$
	Force-to-shield	$\geq$ 5 x 10 <sup>12</sup> $\Omega$	$\geq$ 5 x 10 <sup>12</sup> $\Omega$	$\geq 5 \times 10^{11} \Omega$	$\geq 1 \times 10^{11} \Omega$

#### Coaxial Chuck Performance (200 mm)

	Thermal Chuck @ -60/-55°C	Thermal Chuck @ 25°C	Thermal Chuck @ 200°C	Thermal Chuck @ 300°C
Breakdown voltage	≥ 500 V	≥ 500 V	≥ 500 V	≥ 500 V
Resistance (MicroVac / Hi-ISO)	$\geq$ 1 x 10 <sup>12</sup> $\Omega$	$\geq$ 1 x 10 <sup>12</sup> $\Omega$	$\geq 5 \times 10^{11} \Omega$	$\geq 1 \times 10^{11} \Omega$
Resistance (Basic)	≥ 1 x 10 <sup>11</sup> Ω	≥ 1 x 10 <sup>11</sup> Ω	≥ 1 x 10 <sup>10</sup> Ω	≥ 1 x 10° Ω

#### **System Electrical Performance**

Station with chuck				
(thermal)		FemtoGuard	MicroVac / Hi-ISO	Basic
Probe leakage *	Thermal controller OFF	≤ 1 fA	≤ 1 fA	N/A
	Thermal controller ON	≤ 5 fA	≤ 10 fA	N/A
Chuck leakage * (ATT)	Thermal controller OFF	≤ 2 fA	25 pA	N/A
	-60/-55°C	≤ 6 fA	25 pA	N/A
	25°C	≤ 3 fA	25 pA	N/A
	200°C	≤ 6 fA	25 pA	N/A
	300°C	≤ 6 fA	220 pA	N/A
Residual capacitance		≤ 2.0 pF	N/A	N/A
Capacitance variation **		≤ 3 fF	≤ 75 fF	N/A
Settling time ***	All temperatures @ 10 V	≤ 50 fA @ 50 ms (typical)	N/A	N/A

NOTE: Results measured with thermal chuck at standard probing height (5000  $\mu$ m) with chuck in a dry environment. Moisture in the chuck may degrade performance.

**S**FORMFACTOR™

<sup>\*</sup> Overall leakage current is comprised of two separate components: 1) offset, and 2) noise. Offset is the DC value of current due to instrument voltage offset driving through isolation resistance. Noise is low frequency ripple superimposed on top of offset and is due to disturbances in the probe station environment.

Noise and leakage are measured with a 4156C NOISE.dat CMI program or equivalent; 4ms sample rate, auto scale, 1nA compliance, 1 NPLC integration.

<sup>\*\*</sup> This is chuck capacitance variation based upon chuck position anywhere in the 200 mm area, as measured by a stationary dc probe. Test conditions: Agilent 4284A LCR meter (Cp-d,1 Mhz,4 Ave,0 Power), DCP-150, 75 µm above chuck surface, 4-wire connection (HiZ/Hipot to chuck, Loz/Lopot to Probe), 25°C.

<sup>\*\*\*</sup> Settling time is measured with a 4156C SETLB.dat CMI program or equivalent; 2 ms sampling rate, limited auto 1 nA, 1 µA compliance, 3 NPLC integration.

## > Thermal System Performance

#### **Thermal System Overview**

	········ • <b>/</b>			
Temperature ranges	-55°C to 200°C, ATT, liquid cool (200 mm)			
	-60°C to 300°C, ATT, air cool (200 mm)			
	+20°C to 300°C, ATT, air cool (200 mm)			
	+30°C to 300°C, ATT, air cool (200 mm	n)		
Wafer temperature accuracy	Standard <sup>1, 2</sup>	± 2.5°C at 100°C		
	High Accuracy <sup>3</sup>	± 0.05°C (0 to 250°C)		
Thermal uniformity	FemtoGuard, MicroVac, Hi-Iso <sup>4</sup>	≤ ± 0.5C° @ 25°C, ≤ ± 1.5°C @ -60°C, ≤ ± 0.85°C @ 200°C, ≤ ± 1.5°C @ 300°C		
	Basic Chuck <sup>4</sup>	$\leq$ ± 0.5°C or ± 0.5% of measurement temp up to 200°C, (whichever is greater)		

<sup>1.</sup> As measured with an Anritsu WE-11K-TSI-ANP or WE-12K-GW1-ANP type K thermocouple surface temperature measurement probe with offset calibration procedure. Conditions: closed chamber with minimum recommended purge air, probe centered on a blank silicon wafer, chuck at center of travel and standard probe height. Typical type K thermocouple probe tolerances are ±2.2°C or ±0.75% of the measured temperature in °C (whichever is greater).

- 2. The test setup can change the wafer temperature accuracy from the calibration by  $\pm 5^{\circ}$ C (typical). Test setup attributes include open or closed chamber, probe or probe card construction and number of contacts, purge air flow rate, and lab environmental conditions.
- 3. Special high accuracy calibration using KLA Sense array wafer (Consult factory for pricing and availability)
- 4. As measured at DUT (device under test) probing location.

Note: For physical dimensions and facility requirements, refer to the Summit Facility Planning Guide.

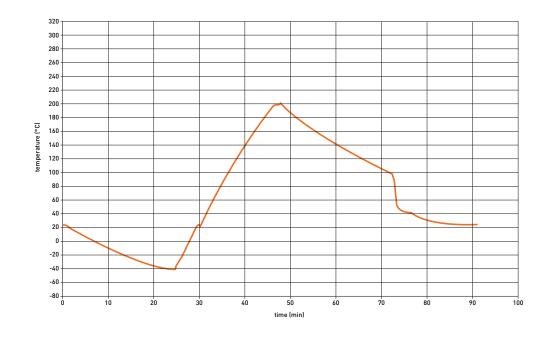
## ATT Thermal System Specifications, 200 mm (liquid cool, -55°C to 200°C)

Temperature range	-55°C to 200°C
Transition time – Heating (-55°C to 25°C)	5 min (typical)
Transition time – Heating (25°C to 200°C)	14 min (typical)
Transition time – Cooling (200°C to 25°C)	34 min (typical)
Transition time – Cooling (25°C to -55°C)	20 min (typical)
Temperature resolution	0.1° C
Audible noise	< 60 dB (A)

7

## ATT Thermal Transition Time (-55°C to 200°C)

 $\label{thm:continuous} \mbox{Typical times using Summit-AP with FemtoGuard Chuck}.$ 





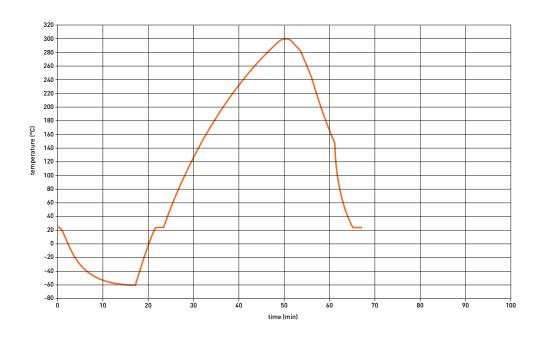
# > Thermal System Performance (Continued)

## ATT Thermal System Specifications, 200 mm (air cool, -60°C to 300°C)

Temperature range	-60°C to 300°C
Transition time – Heating (-60°C to 25°C)	5 min (typical)
Transition time – Heating (25°C to 300°C)	27 min (typical)
Transition time – Cooling (300°C to 25°C)	15 min (typical)
Transition time – Cooling (25°C to -60°C)	15 min (typical)
Temperature resolution	0.1°C
Audible noise	< 60 dB (A)

## ATT Thermal Transition Time (-55°C to 200°C)

Typical times using Summit-AP with FemtoGuard Chuck.





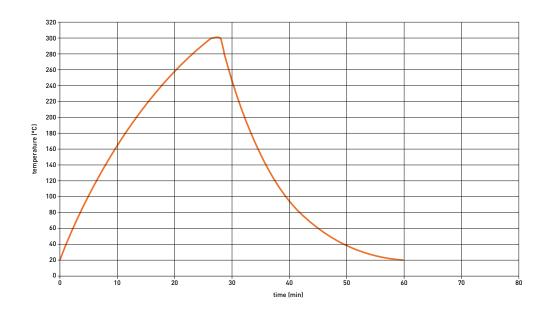
# > Thermal Options and Performance

## ATT Ambient Option Specifications, 200 mm (air cool, + 20°C to 300°C)

Temperature range	+ 20°C to 300°C
Transition time - Heating	27 min 200 mm (typical)
Transition time - Cooling	31 min 200 mm (typical)
Temperature resolution	0.1°C
Audible noise	< 60 dB (A)

## ATT Thermal Transition Time (+20°C to 300°C)

Typical times using Summit-AP with FemtoGuard Chuck.





# > Thermal Options and Performance

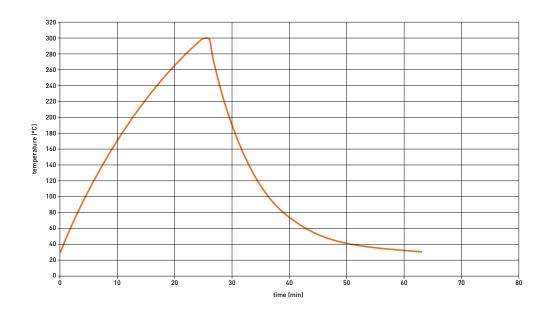
## ATT Ambient Option Specifications, 200 mm (air cool, +30°C to 300°C)

Temperature range	+ 30 to 300°C
Transition time - Heating	25 min (typical)
Transition time - Cooling	36 min (typical)
Temperature resolution	0.1°C
Audible noise	< 60 dB (A)

10

## ATT Thermal Transition Time (+30°C to 300°C)

Typical times using Summit-AP with FemtoGuard Chuck.





Optional high-performance system controller with Velox probe station control software and Windows 10

## > Available Models

Summit 11000B-AP - Probe station platform, manual with MicroChamber, AttoGuard and PureLine technology

Configuration includes:

MicroChamber for dark, dry and enhanced EMI-shielding enclosure

PureLine technology for premium signal path fidelity

AttoGuard for enhanced IV and CV testing

Roll-out wafer stage for safe and easy wafer loading

High-stability platen with linear lift

Precision manual X-Y stage

User guides, tools and accessories

Note: To complete the Summit station platform configuration:

1. Select a modular chuck from the following non-thermal or thermal list

2. Select a matching thermal system if a thermal chuck is desired

#### **Summit Non-Thermal Chucks**

Part Number	General Description
TC-002-30x	FemtoGuard triaxial chuck, non-thermal, 200 mm (8")
TC-002-104	MicroVac coaxial Chuck, high isolation, non-thermal, 200 mm (8")
TC-002-101	Hi-ISO coaxial chuck, non-thermal, 200 mm (8")
TC-002-10x-6	Hi-ISO coaxial chuck, non-thermal, 150 mm (6")

Summit Thermal Chuck		Cooling
Part Number	General Description	
TC-412-30x	FemtoGuard triaxial chuck, thermal, -60°C to 300°C , 200 mm (8"), Ni/Au	Air
TC-412-104	MicroVac coaxial chuck, high isolation, thermal, -60°C to 300°C, 200 mm (8"), Au	Air
TC-412-101	Hi-ISO coaxial chuck, thermal, -60°C to 300°C, 200 mm (8"), Ni	Air
TC-412-001	Basic chuck, coaxial, thermal, -60°C to 300°C, 200 mm (8"), Ni	Air
TC-402-30x	FemtoGuard triaxial chuck, thermal, -55°C to 200°C, 200 mm (8"), Ni/Au	Liquid
TC-402-104	MicroVac coaxial chuck, high isolation, thermal, -55°C to 200°C, 200 mm (8"), Au	Liquid
TC-402-101	Hi-ISO coaxial chuck, thermal, -55°C to 200°C, 200 mm (8"), Ni	Liquid
TC-402-001	Basic chuck, coaxial, thermal, -55°C to 200°C, 200 mm (8"), Ni	Liquid

#### Summit Thermal System (200 mm)

Part Number	General Description
TS-412-02T	Thermal system for Summit, +30°C to 300°C, ATT, air cool (100-230 VAC 50/60 Hz)
TS-412-05T	Thermal system for Summit, +20°C to 300°C, ATT, air cool (100-230 VAC 50/60 Hz)
TS-412-14R	Thermal System, -60°C to 300°C, ATT (200-220 VAC 60 Hz, 200 VAC 50 Hz)
TS-412-14E	Thermal System, -60°C to 300°C, ATT (220-240 VAC 50 Hz)
TS-402-07R	Thermal system for Summit, -55°C to 200°C, ATT, liquid cool (208 VAC 60Hz)
TS-402-07E	Thermal system for Summit, -55°C to 200°C, ATT, liquid cool (230 VAC 50Hz)

Note: Thermal systems must match the thermal chuck selected, i.e. TS-412-xxx thermal systems are compatible only with TC-412-xxx chucks.

**S**FORMFACTOR™

# > Standard Options for Microscope Mounts

Part Number 162-160
50 mm x 50 mm (2 in. x 2 in.)
13 mm x 13 mm (0.5 in. x 0.5 in.)
5 mm (0.2 in.) / turn, coaxial XY control
10 μm (0.4 mils) over full travel with 5 kg (11 lb.) load
4" vertical lift, pneumatic with up/down, for easy probe access
1 μm (0.04 mils)
Coarse/fine focus uses microscope system

Part Number 158-073
200 mm x 125 mm (7.8 in. x 4.9 in.)
13 mm x 13 mm (0.5 in. x 0.5 in.)
5 mm (0.2 in.) / turn
75 μm (3 mils)over full travel with 5 kg (11 lb.) load
150 mm (6 in.) manual linear lift with counterbalance
5 μm (0.2 mils)
Coarse/fine focus uses microscope system

ability Bridge/Transport (programmable) On request
--

12



## > Summit Station Accessories

Microscope / video system	
Vibration isolation table	
Probe card holders	
RF and DC probes, needles and probe cards	
RF and DC cables and adapters	
RF and DC probe psoitioners	
Calibration software and standards	
Vacuum pump, air compressor	

## > Summit Upgrade Options

#### **HTS Enhancements**

High Thermal Stability (HTS) enhancements minimize the thermal drift of the probe supporting components. They are made of high temperature stable materials such as Invar. Using HTS enhancements, transition and die soak time can be minimized to optimize the probe station's productivity.

#### Available Items\*

Part Number	Description
151-293	HTS Probe Card Holder, 40 mm, universal
151-337	HTS platen upgrade
	Various HTS single probe arms*

<sup>\*</sup> See FormFactor's Station Accessory Guide for other available items, such as HTS probe arms and probes tips.

## > Regulatory Compliance

Certification	TÜV compliance tested for CE and CB, certified for US and Canada, SEMI S2 and S8	
---------------	--	--

## ➤ Warranty\*

Warranty	Fifteen months from date of delivery or twelve months from date of installation
Service contracts	Single and multi-year programs available to suit your needs

13

© Copyright 2023 FormFactor, Inc. All rights reserved. FormFactor and the FormFactor logo are trademarks of FormFactor, Inc. All other trademarks are the property of their respective owners.

All information is subject to change without notice.

**Corporate Headquarters** 

7005 Southfront Road Livermore, CA 94551 Phone: 925-290-4000 www.formfactor.com

Summit-DS-0523



<sup>\*</sup>See FormFactor's Terms and Conditions for Sale for more details.